

<b>Search Notes</b> 	<b>Application/Control No.</b> 10/823,845	<b>Applicant(s)/Patent under Reexamination</b> LIN, DAVID HSING
<b>Examiner</b> Navneet K. Ahluwalia	<b>Art Unit</b> 2166	

INTERFERENCE SEARCHED			
Class	Subclass	Date	Examiner